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### Manufacturing method of semiconductor package

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#### Abstract

A manufacturing method of a semiconductor package includes the following steps. A first semiconductor device is provided over a substrate, wherein the first semiconductor device is offset toward an edge of the substrate. A ring structure is attached to the substrate by a first adhesive layer, wherein the ring structure surrounds the first semiconductor device and comprises an overhang portion cantilevered over the edge of the substrate. A lid structure is attached to the ring structure by a second adhesive layer, wherein the lid structure covers the first semiconductor device and comprises an extending portion covering the overhang portion.

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## Background/Summary

CROSS-REFERENCE TO RELATED APPLICATION (1) This is a divisional application of patent application Ser. No. 17/460,349, filed on Aug. 30, 2021. The entirety of each of the above-mentioned patent applications is hereby incorporated by reference herein and made a part of this specification.

### BACKGROUND

(1) Semiconductor devices are used in a variety of electronic applications, such as personal computers, cell phones, digital cameras, and other electronic equipment. Semiconductor devices are typically fabricated by sequentially depositing insulating or dielectric layers, conductive layers, and semiconductor layers of material over a semiconductor substrate, and patterning the various material layers using lithography to form circuit components and elements thereon. Many integrated circuits are typically manufactured on a single semiconductor wafer. The dies of the wafer may be processed and packaged at the wafer level, and various technologies have been developed for wafer level packaging.

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# Description

## BRIEF DESCRIPTION OF THE DRAWINGS

(1) Aspects of the present disclosure are best understood from the following detailed description when read with the accompanying figures. It is noted that, in accordance with the standard practice in the industry, various features are not drawn to scale. In fact, the dimensions of the various features may be arbitrarily increased or reduced for clarity of discussion.

(2) FIG. 1 illustrates a schematic top view of a semiconductor package according to some embodiments of the present disclosure.

(3) FIG. 2 illustrates a schematic cross sectional view of the semiconductor package in FIG. 1 along a-a' line according to some embodiments of the present disclosure.

(4) FIG. 3 illustrates a schematic cross sectional view of the semiconductor package according to some embodiments of the present disclosure.

(5) FIG. 4 illustrates a schematic top view of a semiconductor package according to some embodiments of the present disclosure.

(6) FIG. 5 illustrates a schematic view of a semiconductor package according to some embodiments of the present disclosure.

(7) FIG. 6 illustrates a schematic cross sectional view of the semiconductor package in FIG. 5 along b-b' line according to some embodiments of the present disclosure.

(8) FIG. 7 illustrates a schematic cross sectional view of a semiconductor package according to some embodiments of the present disclosure.

(9) FIG. 8 illustrates a partial enlarged top view of a semiconductor package according to some embodiments of the present disclosure.

(10) FIG. 9 illustrates a partial enlarged top view of a semiconductor package according to some embodiments of the present disclosure.

(11) FIG. 10 to FIG. 14 illustrate cross sectional views of intermediate stages in the manufacturing of a semiconductor package according to some embodiments of the present disclosure.

(12) FIG. 15 to FIG. 16 illustrate cross sectional views of intermediate stages in the manufacturing of a semiconductor package according to some embodiments of the present disclosure.

(13) FIG. 17 illustrates a schematic cross sectional view of a semiconductor package according to some embodiments of the present disclosure.

## DETAILED DESCRIPTION

(14) The following disclosure provides many different embodiments, or examples, for implementing different features of the provided subject matter. Specific examples of components and arrangements are described below to simplify the present disclosure. These are, of course, merely examples and are not intended to be limiting. For example, the formation of a first feature over or on a second feature in the description that follows may include embodiments in which the first and second features are formed in direct contact, and may also include embodiments in which additional features may be formed between the first and second features, such that the first and second features may not be in direct contact. In addition, the present disclosure may repeat reference numerals and/or letters in the various examples. This repetition is for the purpose of simplicity and clarity and does not in itself dictate a relationship between the various embodiments and/or configurations discussed.

(15) Further, spatially relative terms, such as “beneath,” “below,” “lower,” “above,” “upper” and the like, may be used herein for ease of description to describe one element or feature's relationship to another element(s) or feature(s) as illustrated in the figures. The spatially relative terms are intended to encompass different orientations of the device in use or operation in addition to the orientation depicted in the figures. The apparatus may be otherwise oriented (rotated 90 degrees or at other orientations) and the spatially relative descriptors used herein may likewise be interpreted

accordingly.

(16) A semiconductor package and the method of forming the same are provided in accordance with various exemplary embodiments. Before addressing the illustrated embodiments specifically, certain advantageous features and aspects of the present disclosed embodiments will be addressed generally. The semiconductor package may be adopted for improving stress concentration and/or delamination issues during manufacturing process. Described below is a structure having a semiconductor device disposed over a substrate in an offset position (e.g., shift from a center axis of the substrate). Correspondingly, a ring structure surrounding the semiconductor device is cantilevered over the edge of the substrate, which increases a bonding area between the ring structure and the lid structure disposed thereon, so as to avoid or reduce stress concentration and/or delamination issues, especially in the adhesive layer and around die corners. In addition, the manufacturing process can be simplified and production cost can be reduced. The intermediate stages of forming the package are illustrated in accordance with some embodiments. Some variations of some embodiments are discussed. Throughout the various views and illustrative embodiments, like reference numbers are used to designate like elements.

(17) FIG. 1 illustrates a schematic top view of a semiconductor package according to some embodiments of the present disclosure. FIG. 2 illustrates a schematic cross sectional view of the semiconductor package in FIG. 1 along a-a' line according to some embodiments of the present disclosure. With now reference to FIG. 1 and FIG. 2, in some embodiments, a semiconductor package **100** includes a substrate **110**, a (first) semiconductor device **120**, and a ring structure **132**. In some embodiments, the substrate **110** is a package substrate, which may be a built-up substrate or a laminate substrate. In some other embodiments, the substrate **110** may be an interposer, which includes a dielectric substrate or a semiconductor substrate (such as a silicon substrate). Conductive redistribution lines (not shown) are formed in the substrate **110** to electrically inter-couple the conductive features on opposite sides of the substrate **110**. In some embodiments,

(18) In accordance with some embodiments of the disclosure, the semiconductor device **120** is disposed over the substrate **110**. The semiconductor device **120** may be a device die that include active devices such as transistors. In some embodiments, the semiconductor device **120** may include a workpiece, which includes silicon or other semiconductor materials that may be covered by an insulating layer, for example. The workpieces of the semiconductor device **120** may include active components or circuits, not shown, such as transistors, diodes, resistors, capacitors, etc. In some embodiments, the semiconductor device **120** is a logic die, which may include a system on chip (SoC), and may include elements such as a CPU (central processing unit), a memory controller, and other related system elements. In some embodiments, the semiconductor device **120** may include one or more stacked dielectric, conductive, and/or semiconductor layers. For example, the semiconductor device **120** may correspond to one or more overlaid memory devices (e.g., flash memory and DRAM memory), one or more processors or processor cores (e.g., CPU cores), other digital logic, or combinations thereof.

(19) In accordance with some embodiments of the disclosure, the semiconductor device **120** is mounted on over the substrate **110** in an offset position toward an edge E1 of the substrate **110**. In other words, the semiconductor device **120** is deviated from a center axis (long axis) CL (e.g., the center axis CL parallel to the edge E1) of the substrate **110** by a certain distance. Accordingly, a distance d2 between the edge E1 of the substrate **110** and the respective (closest) side of the semiconductor device **120** is substantially smaller than a distance d1 between an opposite edge E2 (opposite to the edge E1) of the substrate **110** and the respective (closest) side of the semiconductor device **120**. In some embodiments, the semiconductor device **120** is disposed in the offset position on the substrate **110** for design and/or layout purposes. For example, the semiconductor device **120** may be offset from the center of the substrate **110** to make room for a surface mounted device **122**, but the disclosure is not limited thereto. In such embodiment, the surface mounted device **122** may be disposed over the substrate **110** and adjacent to the semiconductor device **120**. In some

embodiments, the surface mounted device **122** is closer to the opposite edge **E2** of the substrate **110**. In some embodiments, the surface mounted device **122** may be a passive device (e.g., capacitors, resistors, inductors, varactors, and/or the like). The placement of the surface mounted device **122** may include surface mount technology (SMT) connections, for example.

(20) In some embodiments, a ring structure **132** is disposed over the substrate **110** and surrounding the semiconductor device **120**. In some embodiments, the ring structure **132** may be thermally conductive, and formed of metals such as copper, aluminum, or the like. The ring structure **132** may have a ring shape in the top view as it is shown in FIG. **1**, and may be a full (continuous) ring or a partial (discontinuous) ring. The ring structure **132** includes an overhang portion **1321** that is cantilevered over the edge **E1** of the substrate **110**. In some embodiments, a major outline of the ring structure **132** is substantially aligned with an outline of the substrate **110** from a top view, and the overhang portion **1321** is protruded from the major outline as it is shown in FIG. **1**. In some embodiments, a length **L1** of the overhang portion **1321** is substantially greater than a length **L2** of the respective (closer) side of the semiconductor device **120**, and the length **L1** is substantially equal to or shorter than a length **W2** of the edge **E1** of the substrate **110**. In some embodiments, the length **L1** of the overhang portion **1321** may be substantially greater than a width **W1** of the overhang portion **1321**. In an alternative embodiment, the length **L1** may be substantially shorter than the width **W1**. In some embodiments, a thickness **T1** of the overhang portion **1321** may be substantially greater than the width **W1** of the overhang portion **1321**. In an alternative embodiment, the thickness **T1** may be substantially equal to or shorter than the width **W1**. However, the dimension relationships between components described above are merely for illustration, and not intended to limit the disclosure.

(21) In some embodiments, the semiconductor package **100** may further include a (first) adhesive layer **140** disposed between the substrate **110** and the ring structure **132** for attaching the ring structure **132** to the substrate **110**. The adhesive layer **140** may include a thermal interface material (TIM) dispensed on to the top surface of the substrate **110**. TIM has a relatively higher thermal conductivity (hence the name) than typical adhesive materials. In some embodiments, the adhesive layer **140** may include an organic material, and may also act as an adhesive. In some embodiments, the adhesive layer **140** may include a polymer matrix, a phase change polymer, a silicone-based matrix, a matrix additive (fluxing agent), a filler material (a metallic core with an organic solderability preservative coating), or the like.

(22) In general, during process, the different materials, which make up the semiconductor package **100**, expand and contract at different rates (i.e. relative expansion rates) which imply a mismatch in their coefficient of thermal expansion (CTE). This CTE mismatch of the materials in the semiconductor package **100** (e.g., materials of substrate **110**, semiconductor device **120**, adhesive layer **140**, and ring structure **132**) is responsible for reliability issues such as stress concentration, delamination, etc., especially in the adhesive layer and around die corners. In the case of semiconductor package **100** being asymmetrical (e.g., the semiconductor device **120** being offset from the center axis **CL** of the substrate **110**), the semiconductor package **100** would be even more mechanically unbalanced. This asymmetry, along with different materials used in the packaging (e.g., CTE mismatch between materials of substrate **110**, semiconductor device **120**, adhesive layer **140**, and ring structure **132**, etc.), cause both mechanical and thermal stresses, which in turn lead to package warpage and co-planarity issues. Package warpage can place stress on the solder joints of the semiconductor device **120**, especially around device corners, leading to detachment of some of the solder bumps and/or physical damage to the device **120**. Furthermore, such package warp can cause detachment (e.g., delamination) of semiconductor device **120** from the ring structure **132** by adhesive layer **140**.

(23) If the outline of the ring structure **132** is entirely aligned with the outline of the substrate **110** from a top view (i.e., no overhang portion **1321**), the bulk of the ring structure **132** on the edge **E1** would be smaller than that on the opposite edge **E2**. In addition, bonding (contact) area between the

substrate **110** and the ring structure **132** on the edge **E1** would also be smaller than that on the opposite edge **E2**, which would make worse the reliability issue such as stress concentration, delamination, etc., especially in the adhesive layer **140** and around die corners. Therefore, the ring structure **132** is configured with the overhang portion **1321** cantilevered over the edge **E1** of the substrate **110**, which increases the mechanical strength of the semiconductor package **100** and balances out the proportion of materials on each side. Thereby, reliability issues such as stress concentration (in adhesive layer around die corners, for example) and delamination due to CTE mismatch in the asymmetrical semiconductor package **100** can be avoided or at least significantly reduced. In experimental perspective, the warpage of the semiconductor package **100** is reduced about 5% to 10% compared to the asymmetrical semiconductor package without the overhang portion **1321**.

(24) FIG. **3** illustrates a schematic cross sectional view of the semiconductor package according to some embodiments of the present disclosure. It is noted that the semiconductor package **100a** shown in FIG. **3** contains many features same as or similar to the semiconductor package **100a** disclosed earlier with FIG. **1** and FIG. **2**. For purpose of clarity and simplicity, detail description of same or similar features may be omitted, and the same or similar reference numbers denote the same or like components. The main differences between the semiconductor package **100a** shown in FIG. **3** and the semiconductor package **100** shown in FIG. **1** and FIG. **2** are described as follows.

(25) With now reference to FIG. **3**, in some embodiments, the semiconductor package **100a** may further include a lid structure **134** disposed over the ring structure **132** and covering the semiconductor device **120**. The lid structure **134** may be formed of a metal or a metal alloy that has a high thermal conductivity. The lid structure **134** may be formed of the same material as the ring structure **132** is formed of. In an alternative embodiment, the lid structure **134** and the ring structure **132** may be formed of different materials. The lid structure **134** includes an extending portion **1341**, which covers the overhang portion **1321** of the ring structure **132**. In some embodiments, an outline of the extending portion **1341** is substantially aligned with an outline of the overhang portion **1321** from a top view (the top view of the lid structure **34** may be reference to FIG. **5**, with or without the opening patterns **OP**). In other words, a side surface of the extending portion **1341** are substantially coplanar with respective side surface of the overhang portion **1321**. In one of the implementations, the entire outline of the lid structure **134** may be substantially aligned with the entire outline of the ring structure **132** from a top view (the top view of the outline may be reference to FIG. **5**). Accordingly, the ring structure **132** surrounding the semiconductor device **110** and the lid structure **134** covering the semiconductor device **110** are assembled together and jointly form a cover **130**. As such, the cover **130**, which is disposed over the substrate **110**, surrounds and covers the semiconductor device **120**. In some embodiments, a major outline of the cover **130** is substantially aligned with an outline of the substrate **110** from a top view, and the overhang portion **1321** along with the extending portion **1341** are protruded from the major outline of the substrate **110**. In some embodiments, a thickness **T2** of the lid structure **134** may be greater than the thickness **T1** of the ring structure **132**. In an alternative embodiments, the thickness **T2** of the lid structure **134** may be substantially equal to or smaller than the thickness **T1** of the ring structure **132**. The disclosure is not limited thereto.

(26) In some embodiments, the lid structure **134** may be attached onto the ring structure **132** by an (second) adhesive layer **160**. The adhesive layer **160** may include a material that is selected from the same group of candidate materials of adhesive layer **140**. In some embodiments, the adhesive layer **160** may also include thermal interface material and be disposed between the lid structure **134** and the ring structure **132**. In some embodiments, the adhesive layer **160** is comprehensively distributed over an upper surface of the ring structure **132** that faces the lid structure **134**. To be more specific, the adhesive layer **160** completely covers an upper surface of the overhang portion **1321** that faces the extending portion **1341** of the lid structure **134**. Thereby, the bonding strength between the ring structure **132** and the lid structure **134** is improved, which increases the

mechanical strength of the semiconductor package **100** and balances out the proportion of materials in the semiconductor package **100a**. Accordingly, reliability issues such as stress concentration (in the adhesive layer **160**, for example) and delamination due to CTE mismatch in the asymmetrical semiconductor package **100a** can be avoided or at least significantly reduced. In experimental perspective, the stress in the adhesive layer **160** is reduced about 25% to 35% compared to the cover without the overhang portion, and the warpage of the semiconductor package **100** is reduced about 5% to 10% compared to the asymmetrical semiconductor package without the overhang portion.

(27) FIG. **4** illustrates a schematic top view of a semiconductor package according to some embodiments of the present disclosure. FIG. **5** illustrates a schematic view of a semiconductor package according to some embodiments of the present disclosure. FIG. **6** illustrates a schematic cross sectional view of the semiconductor package in FIG. **5** along b-b' line according to some embodiments of the present disclosure. It is noted that the semiconductor package **100b** shown in FIG. **4** to FIG. **6** contains many features same as or similar to the semiconductor packages disclosed earlier. For purpose of clarity and simplicity, detail description of same or similar features may be omitted, and the same or similar reference numbers denote the same or like components. It is noted that, for clarity and simplicity purposes, the lid structure in FIG. **4** is omitted for better illustrating the structure underneath. The main differences between the semiconductor package **100b** shown in FIG. **4** to FIG. **6** and the semiconductor packages disclosed earlier are described as follows.

(28) With now reference to FIG. **4** and FIG. **5**, in some embodiments, the semiconductor package **100b** may further include at least one (second) semiconductor device **150** disposed over the substrate **110**. The semiconductor devices **150** are disposed on the substrate **110** in a side by side manner with the semiconductor device **120**. In some embodiments, the semiconductor device **120** is surrounded by the semiconductor devices **150**. In some embodiments, the semiconductor device **120** is a logic die, and semiconductor devices **150** are memory dies, although semiconductor devices **120** and **150** may be other types of dies having other functions in any combination. In some embodiments, the semiconductor device **120** may be a single system on chip (SoC) die, multiple SoC stacked dies, or the like. In some embodiments, each of the semiconductor devices **150** may be a dynamic random access memory (DRAM), a high bandwidth memory (HBM), a chip scale package (CSP), or the like. While FIG. **4** illustrates the semiconductor package **100b** having one semiconductor device **120** and two semiconductor devices **150**, other embodiments may include any number of semiconductor device **120** and/or semiconductor device **150**. In other embodiment, an encapsulating material (not shown) may encapsulate the semiconductor devices **120** and **150** therein, and the top surfaces of semiconductor devices **120** and **150** may be exposed. It is noted that the cross sectional view of the semiconductor package **100b** along a-a' line in FIG. **5** may be the same or at least similar to the cross sectional view shown in FIG. **3**.

(29) In accordance with some embodiments of the disclosure, the semiconductor devices **150** may be arranged along a center axis (e.g., the center axis CL illustrate in FIG. **1**) of the substrate **110** that is parallel to the edge E1 while the semiconductor device **120** is offset (deviated) from the center axis of the substrate **110** by a certain distance. In other words, the semiconductor device **120** is offset (deviated) from a center axis of the semiconductor devices **150** parallel to the edge E1. A surface mounted device (not shown) may be disposed adjacent to the semiconductor device **120** and closer to the opposite edge E2 of the substrate **110**. That is, the semiconductor device **120** may be offset from the center of the substrate **110** to make room for a surface mounted device **122**, but the disclosure is not limited thereto.

(30) Accordingly, the cover **130** including the ring structure **132** and the lid structure **134** is disposed over the substrate **110** for surrounding and covering the semiconductor devices **120** and **150**. The cover **130** includes the overhang portion **1321** from the ring structure **132** and the extending portion **1341** from the lid structure **134** assembled together to be cantilevered over the

edge E1 of the substrate **110**. In some embodiments, a major outline of the cover **130** is substantially aligned with an outline of the substrate **110** from a top view, and the overhang portion **1321** along with the extending portion **1341** is protruded from the major outline.

(31) With now reference to FIG. 5 and FIG. 6, in some embodiments, the semiconductor devices **120** and **150** each have their own heights, which may be equal to one another or different from one another. Accordingly, in the embodiment of the semiconductor devices **150** are higher than the semiconductor device **120**, the cover **130** may further include at least one opening pattern OP corresponding to a back surface of the semiconductor devices **150** (or the semiconductor device(s) whichever is higher) for revealing the back surfaces of the semiconductor devices **150**. In some embodiments, the cover **130** includes opening patterns OP, with each of semiconductor devices **150** extending into one of the opening patterns OP. The quantity of the opening patterns OP may correspond to the quantity of the semiconductor devices **150**, or quantity of semiconductor devices **120** and/or **150** that need to extend into the opening patterns OP. In some embodiments, the adhesive layer **160** may be applied to the back surface of the semiconductor device **120** (or the semiconductor device(s) whichever is lower in height), so, when the cover **130** is disposed over, the semiconductor device **120** can be thermally coupled to the cover **130** directly through the adhesive layer **160**. As such, the depths and the widths of the opening patterns OP in the cover **130** may be chosen, so that the adhesive layer **160** have small thicknesses in order to have good heat dissipating efficiency.

(32) FIG. 7 illustrates a schematic cross sectional view of a semiconductor package according to some embodiments of the present disclosure. It is noted that the semiconductor package **100c** shown in FIG. 7 contains many features same as or similar to the semiconductor package **100b** shown in FIG. 4 to FIG. 6. For purpose of clarity and simplicity, detail description of same or similar features may be omitted, and the same or similar reference numbers denote the same or like components. The main differences between the semiconductor package **100c** shown in FIG. 7 and the semiconductor package **100b** disclosed earlier are described as follows.

(33) In accordance with some embodiments of the disclosure, as shown in FIG. 7, for the semiconductor package **100c** that the heights of the semiconductor devices **120** and **150** are substantially the same or similar to one another, the cover **130** may cover the semiconductor devices **120** and **150** altogether. That is, the cover **130** may not have any opening patterns shown in FIG. 6. In some embodiments, the adhesive layer **160** may be applied to the back surfaces of the semiconductor devices **120** and **150**, so that, when the cover **130** is disposed thereon, the semiconductor devices **120** and **150** can be thermally coupled to the cover **130** directly through the adhesive layer **160**. Namely, the adhesive layer **160** is disposed between and in contact with the cover **130** and the semiconductor devices **120** and **150** in order to have good heat dissipating efficiency. In such embodiment, the heights of the semiconductor devices **120** and **150** may still be different from one another and the adhesive layer **160** may be applied to the back surfaces of the semiconductor devices **120** and **150** with different thickness to compensate the height differences of the semiconductor devices **120** and **150**.

(34) FIG. 8 illustrates a partial enlarged top view of a semiconductor package according to some embodiments of the present disclosure. Referring to FIG. 8, in some embodiments, as it is mentioned earlier, the CTE mismatch of the materials in the semiconductor package is responsible for reliability issues such as stress concentration, delamination, etc. In the case of semiconductor package being asymmetrical (e.g., the semiconductor device **120** being offset from the center axis CL of the substrate **110**), the asymmetry, along with different materials used in the packaging would cause both mechanical and thermal stresses concentration, especially around the corners of the semiconductor device **120** that is closer to the edge E1. Accordingly, in some embodiments, the length L1 of the overhang portion **1321** and the extending portion **1341** is substantially greater than the length L2 of the semiconductor device **120**, so as to ensure the corners of semiconductor device **120** closer to the edge E1 being well surrounded and reinforced by the cover **130**. Thereby, the



mechanical strength around the corners of semiconductor device **120** closer to the edge **E1** can be improved. In the present embodiment, the length **L1** of the overhang portion **1321** and the extending portion **1341** is substantially greater than the width of the overhang portion **1321** and the extending portion **1341**. In an alternative embodiments, the length **L1** of the overhang portion **1321** and the extending portion **1341** may be substantially equal to or smaller than the width of the overhang portion **1321** according to the design and layout requirement of the semiconductor package.

(35) FIG. **9** illustrates a partial enlarged top view of a semiconductor package according to some embodiments of the present disclosure. It is noted that the semiconductor package shown in FIG. **9** contains many features same as or similar to the semiconductor packages disclosed earlier. For purpose of clarity and simplicity, detail description of same or similar features may be omitted, and the same or similar reference numbers denote the same or like components. The main differences between the semiconductor package shown in FIG. **9** and the semiconductor packages disclosed earlier are described as follows.

(36) As shown in FIG. **9**, in some embodiments, since the area around the corners of the semiconductor device **120** closer to the edge **E1** endures more severe mechanical and thermal stresses concentration, the cover **130** may include more than one overhang portions **1321a**, **1321b** along with more than one corresponding extending portions **1341a**, **1341b**, which are disposed correspondingly to respective corners (e.g., corners **C1**, **C2**) of the semiconductor device **120** that are closer to the edge **E1**. Accordingly, the corners of semiconductor device **120** closer to the edge **E1** can be well surrounded and reinforced by the respective overhang portions **1321a**, **1321b** and the extending portions **1341a**, **1341b**, and the mechanical strength around the corners **C1**, **C2** of semiconductor device **120** can be improved. In accordance with some embodiments of the disclosure, a gap **P1** between adjacent two of the overhang portions **1321a**, **1321b** is substantially shorter than a quarter of a distance **L3** between two outermost sides of the overhang portions **1321a**, **1321b** (i.e.,  $P1 < L3/4$ .) The same configuration may also be applied to the extending portions **1341a**, **1341b** correspondingly. However, the dimension relationships between components described above are merely for illustration, and not intended to limit the disclosure.

(37) FIG. **10** to FIG. **14** illustrate cross sectional views of intermediate stages in the manufacturing of a semiconductor package according to some embodiments of the present disclosure. FIG. **10** to FIG. **14** depict one of the manufacturing processes of one of the semiconductor packages for illustration purpose. The disclosure is not limited thereto. For purpose of clarity and simplicity, detail description of same or similar features may be omitted, and the same or similar reference numbers denote the same or like components.

(38) Referring to FIG. **10** and FIG. **10A**, it is noted that FIG. **10A** illustrates a different cross sectional view of the same structure shown in FIG. **10** for showing the semiconductor devices **150**. For example, FIG. **10** shows the cross sectional view along a short axis (e.g., the a-a' line shown in FIG. **4**) of the substrate **110**, and the FIG. **10A** shows the cross sectional view along a long axis (e.g., the b-b' line shown in FIG. **4**) of the substrate **110**. In accordance with some embodiments of the disclosure, at least one (first) semiconductor device **120** and at least one (second) semiconductor device **150** are provided over the substrate **110**. In some embodiments, the substrate **110** may be a package substrate, such as a printed circuit board (PCB), an organic substrate, a ceramic substrate, a motherboard, or the like, which may be a built-up substrate or a laminate substrate. Conductive redistribution lines (not shown) are formed in the substrate **110** to electrically inter-couple the conductive features on opposite sides of the substrate **110**. The substrate **110** may further include contacts (e.g., ball grid array (BGA) balls) disposed on a surface opposite to the surface where the semiconductor devices **120** and **150** are disposed. Alternatively, the substrate **110** may include other types of materials and configurations. The semiconductor devices **120** and **150** may be device dies that include active devices such as transistors. In some embodiments, the semiconductor device **120** is a logic die, and the semiconductor devices **150** are memory dies,

although the semiconductor devices **120** and **150** may be other types of dies in any combination.

(39) In accordance with some embodiments of the disclosure, the semiconductor device **120**, as previously described, is offset from a center axis CL (e.g., long axis) of the substrate **110** by a certain distance **S1**. For example, the semiconductor device **120** is offset toward the edge **E1** of the substrate **110** by the distance **S1**. In some embodiments, the semiconductor device **120** is disposed in the offset position on the substrate **110** for design and/or layout purposes. For example, the semiconductor device **120** may be offset from the center axis CL of the substrate **110** to make room for the surface mounted device **122**, but the disclosure is not limited thereto. The semiconductor devices **150** are disposed on the substrate **110** in a side by side manner with the semiconductor device **120** in accordance with various embodiments. In some embodiments, the semiconductor device **120** is surrounded by the semiconductor devices **150**. In some embodiments, the semiconductor devices **150** may be arranged along the center axis CL of the substrate **110** that is parallel to the edge **E1** while the semiconductor device **120** is offset (deviated) from the center axis CL of the substrate **110** by the certain distance **S1**.

(40) In some embodiments, the semiconductor devices **120** and **150** are bonded to the top surface of the substrate **110** by a plurality of conductive bumps **105**. The conductive bumps **105** are coupled between contact pads (not shown) on the substrate **110** and contact pads (also not shown) on the semiconductor devices **120** and **150**. The conductive bumps **105** includes micro bumps in accordance with various embodiments. In some embodiments, the conductive bumps **105** include controlled collapse chip connection (C4) bumps; however, the conductive bumps **105** may alternatively include other types of electrical connections. A reflow process is performed to reflow and bond the conductive bumps **105** to the substrate **110**. Subsequently, an underfill **106** may be dispensed between semiconductor devices **120** and **150** and the substrate **110**.

(41) Then, referring to FIG. **11**, a dispenser DP dispenses the adhesive layer **140** onto an upper surface of the substrate **110** where the ring structure **132** is to be disposed. In some embodiments, the adhesive layer **140** may include TIM, which has a relatively higher thermal conductivity (hence the name) than typical adhesive materials. The adhesive layer **140** may include an organic material, and may also act as an adhesive. In some embodiments, the adhesive layer **140** includes a polymer matrix, a phase change polymer, a silicone-based matrix, a matrix additive (fluxing agent), a filler material (a metallic core with an organic solderability preservative coating), or the like. The adhesive layer **140** is dispensed in a liquid form that has a high viscosity in accordance with various embodiments. Alternatively, the adhesive layer **140** may be an adhesive tape.

(42) With now reference to FIG. **12**, in some embodiments, the ring structure **132**, which is thermally conductive, and may be formed of metals such as copper, aluminum, or the like, is mounted over the substrate **110** by the adhesive layer **140**. The ring structure **132** may have a ring shape in the top view as it is shown in FIG. **1** and FIG. **4**, and may be a full ring or a partial ring. The ring structure **132**, as previously described, surrounds the semiconductor devices **120** and **150** and includes an overhang portion **1321** that is cantilevered over the edge **E1** of the substrate **110**. The pressure may also be used to reduce the thickness of adhesive layer **140**. A curing step is then performed to cure the adhesive layer **140**, so that the ring structure **132** is adhered to the adhesive layer **140**.

(43) With now reference to FIG. **13** and FIG. **13A**, it is noted that FIG. **13A** illustrates a different cross sectional view of the same resultant structure shown in FIG. **13** for showing the semiconductor devices **150**. For example, FIG. **13** shows the cross sectional view along the short axis (e.g., the a-a' line shown in FIG. **4**) of the substrate **110**, and the FIG. **13A** shows the cross sectional view along the long axis (e.g., the b-b' line shown in FIG. **4**) of the substrate **110**. In accordance with some embodiments of the disclosure, the dispenser DP further dispenses the adhesive layer **160** over an upper surface of the ring structure **132**. In some embodiments, the adhesive layer **160** comprehensively distributed over (i.e., completely covers) an upper surface of the overhang portion **1321** to be bonded with the extending portion **1341** of the lid structure **134**. In

some embodiments, the adhesive layer **160** may also be dispensed over the back surfaces of the semiconductor devices **120** and **150**. The adhesive layer **160** may include a material that is selected from the same group of candidate materials of adhesive layer **140**. Furthermore, the adhesive layers **140** and **160** may include the same material, or different materials.

(44) Then, referring to FIG. **14**, in some embodiments, the lid structure **134** is mounted over the ring structure **132** by the adhesive layer **160**. In accordance with some embodiments of the disclosure, the mounting of the lid structure **134** may use a suction head (not shown), which picks up the lid structure **134** through vacuuming, and places the lid structure **134** over the adhesive layer **160** in accordance with various embodiments. The adhesive layer **160** may be formed of a metal or a metal alloy that has a high thermal conductivity. A pressure may be applied to ensure the good contact of lid structure **134** to the adhesive layer **160** on the ring structure **132** and the semiconductor devices **120**, **150** (not shown from this cross sectional view). The pressure may also be used to reduce the thickness of adhesive layer **160** (and adhesive layer **140** if it has not been fully cured yet). A curing step is then performed to cure the adhesive layer **160** (and possibly the adhesive layer **140**), so that the lid structure **134** is adhered to the adhesive layer **160**. The lid structure, as previously described, covers the semiconductor device **120** and the semiconductor devices **150** (not shown from this cross sectional view) and includes the extending portion **1341** covering the overhang portion **1321**. The adhesive layer **160** is comprehensively covers the upper surface of the overhang portion **1321** facing the extending portion **1341**, so the overhang portion **1321** is comprehensively bonded with the extending portion **1341**. Thereby, the bonding strength between the ring structure **132** and the lid structure **134** is improved, which increases the mechanical strength of the semiconductor package and balances out the proportion of materials in the semiconductor package. Accordingly, reliability issues such as stress concentration (in the adhesive layer **160**, for example) and delamination due to CTE mismatch in the asymmetrical semiconductor package can be avoided or at least significantly reduced.

(45) FIG. **15** to FIG. **16** illustrate cross sectional views of intermediate stages in the manufacturing of a semiconductor package according to some embodiments of the present disclosure. It is noted that the manufacturing process of the semiconductor package shown in FIGS. **15** and **16** contains many features same as or similar to the manufacturing process of the semiconductor package disclosed earlier. For purpose of clarity and simplicity, detail description of same or similar features may be omitted, and the same or similar reference numbers denote the same or like components. The main differences between the manufacturing process of the semiconductor package shown in FIGS. **15** and **16** and the manufacturing process of the semiconductor package disclosed earlier are described as follows.

(46) Referring to FIG. **15** and FIG. **16**, in some embodiments, the heights of the semiconductor devices **120** and **150** may be different from one another. In the present embodiment, the semiconductor devices **150** are higher than the semiconductor device **120**. Accordingly, the lid structure **134**, as shown in FIG. **16**, may further include opening patterns OP corresponding to the back surfaces of the semiconductor devices **150** (or the semiconductor device(s) whichever is higher), so that a part of the semiconductor devices **150** may be extended into the corresponding opening patterns OP. The quantity of the opening patterns OP may corresponding to the quantity of the semiconductor devices **150**, or quantity of semiconductor devices **120** and/or **150** that need to be extended into the opening patterns OP. In some embodiments, the adhesive layer **160** may be applied to the back surface of the semiconductor device **120** (or the semiconductor device(s) whichever is lower in height), so, when the lid structure **134** is disposed over, the semiconductor device **120** can be thermally coupled to the lid structure **134** directly through the adhesive layer **160**. As such, the depths and the widths of the opening patterns OP in the lid structure **134** may be chosen, so that the adhesive layer **160** have small thicknesses in order to have good heat dissipating efficiency.

(47) FIG. **17** illustrates a schematic cross sectional view of a semiconductor package according to

some embodiments of the present disclosure. It is noted that the semiconductor package shown in FIG. 17 contains many features same as or similar to the semiconductor packages disclosed earlier. For purpose of clarity and simplicity, detail description of same or similar features may be omitted, and the same or similar reference numbers denote the same or like components. The main differences between the semiconductor package shown in FIG. 17 and the semiconductor packages disclosed earlier are described as follows.

(48) Referring to FIG. 17, in some embodiments, a package **101** including the semiconductor device **120** disposed between the semiconductor devices **150** are provided. In some embodiments, the semiconductor device **120** may be a single system on chip (SoC) die, multiple SoC stacked dies, or the like, which is high-power consuming die and may consume a relatively high amount of power, and hence generate a relatively large amount of heat, compared to the semiconductor devices **150**. In some embodiments, the semiconductor devices **150** may be HBM (high bandwidth memory) and/or HMC (high memory cube) modules, which may include memory dies bonded to a logic die. In alternative embodiments, the semiconductor devices **120** and **150** may be other chips having other functions.

(49) As illustrated by FIG. 17, the semiconductor devices **120** and **150** are bonded to a top surface of a package component (e.g., interposer **180**) through a plurality of connectors **182**, which may be micro bumps. In alternative embodiments, the semiconductor devices **120** and **150** may be bonded to a different package component such as a substrate, a printed circuit board (PCB), or the like. The semiconductor device **120**, as previously described, is offset from a center axis of the interposer **180**. The semiconductor devices **150**, as previously described, are disposed on the substrate **110** in a side by side manner with the semiconductor device **110** in accordance with various embodiments. In some embodiments, the semiconductor devices **150** may be arranged along the center axis of the interposer **180** while the semiconductor device **120** is offset (deviated) from the center axis of the interposer **180**.

(50) In accordance with some embodiments of the disclosure, the interposer **180** may be a wafer having interconnect structures for electrically connecting active devices (not shown) in the semiconductor devices **120** and **150** to form functional circuits. A connector **182** of the semiconductor devices **120** and **150** is electrically connected to a contact pad on a top side of interposer **180**. One of the through substrate vias (TSVs) **184** may electrically connect to one of the connectors **186** on a backside of interposer **180** in accordance with various embodiments. In an embodiment, the connectors **186** may be controlled collapse chip connection (C4) bumps including solder. The connectors **186** may have a larger critical dimension (e.g., pitch) than the connectors **182**. Other configurations of interposer **18** may also be used. The semiconductor devices **120** and **150** may be encapsulated in an encapsulating material **190** in accordance with various embodiments.

(51) In some embodiments, the package **101** is then bonded to the substrate **110** using the connectors **186**. The resulting chip on wafer on substrate (CoWoS) package is illustrated in FIG. 17. The substrate **110**, as previously described, may be any suitable package substrate, such as a printed circuit board (PCB), an organic substrate, a ceramic substrate, a motherboard, or the like. The substrate **110** may be used to interconnect the package **101** with other packages/devices to form functional circuits. In some embodiments, these other packages and devices may also be disposed on a surface of the substrate **110**. The substrate **110** may further include contacts **60** (e.g., ball grid array (BGA) balls) disposed on a surface opposite to the package **101** in accordance with various embodiments. The contacts **60** may be used to electrically connect the package **101** to a motherboard (not shown) or another device component of an electrical system. The ring structure **132** and the lid structure **134**, as previously described, may be mounted over the substrate **110** to provide mechanical strength to the asymmetrical semiconductor package **100d**.

(52) Based on the above discussions, it can be seen that the present disclosure offers various advantages. It is understood, however, that not all advantages are necessarily discussed herein, and

other embodiments may offer different advantages, and that no particular advantage is required for all embodiments.

(53) In accordance with some embodiments of the disclosure, a semiconductor package includes a substrate, a first semiconductor device and a ring structure. The first semiconductor device is disposed over the substrate in an offset position toward an edge of the substrate. The ring structure is disposed over the substrate and surrounds the first semiconductor device. The ring structure includes an overhang portion cantilevered over the edge of the substrate.

(54) In accordance with some embodiments of the disclosure, a semiconductor package includes a substrate, a first semiconductor device and a cover. The first semiconductor device is disposed over the substrate and offset toward an edge of the substrate. The cover is disposed over the substrate, wherein the cover surrounds and covers the first semiconductor device and includes an overhang portion cantilevered over the edge of the substrate.

(55) In accordance with some embodiments of the disclosure, a manufacturing method of a semiconductor package includes the following steps. A first semiconductor device is provided over a substrate, wherein the first semiconductor device is offset toward an edge of the substrate. A ring structure is attached to the substrate by a first adhesive layer, wherein the ring structure surrounds the first semiconductor device and includes an overhang portion cantilevered over the edge of the substrate. A lid structure is attached to the ring structure by a second adhesive layer, wherein the lid structure covers the first semiconductor device and includes an extending portion covering the overhang portion.

(56) The foregoing outlines features of several embodiments so that those skilled in the art may better understand the aspects of the present disclosure. Those skilled in the art should appreciate that they may readily use the present disclosure as a basis for designing or modifying other processes and structures for carrying out the same purposes and/or achieving the same advantages of the embodiments introduced herein. Those skilled in the art should also realize that such equivalent constructions do not depart from the spirit and scope of the present disclosure, and that they may make various changes, substitutions, and alterations herein without departing from the spirit and scope of the present disclosure.

## Claims

1. A manufacturing method of a semiconductor package, comprising: providing a first semiconductor device over a substrate, wherein the first semiconductor device is offset toward an edge of the substrate; attaching a ring structure to the substrate by a first adhesive layer, wherein the ring structure surrounds the first semiconductor device and comprises an overhang portion cantilevered over the edge of the substrate, wherein a length of the overhang portion is substantially shorter than a length of the edge of the substrate from a top view; and attaching a lid structure to the ring structure by a second adhesive layer, wherein the lid structure covers the first semiconductor device and comprises an extending portion covering the overhang portion.
2. The manufacturing method of the semiconductor package as claimed in claim 1, wherein the second adhesive layer completely covers an upper surface of the overhang portion facing the extending portion.
3. The manufacturing method of the semiconductor package as claimed in claim 1, further comprising: performing a curing process for curing the first adhesive layer and the second adhesive layer.
4. The manufacturing method of the semiconductor package as claimed in claim 1 further comprising: providing a surface mounted device over the substrate, wherein the surface mounted device is closer to an opposite edge that is opposite to the edge of the substrate.
5. The manufacturing method of the semiconductor package as claimed in claim 1, further comprising: providing a second semiconductor device over the substrate in a side by side manner

with the first semiconductor device along the edge.

6. The manufacturing method of the semiconductor package as claimed in claim 5, wherein a height of the second semiconductor device is higher than a height of the first semiconductor device, and the lid structure further comprises an opening pattern corresponding to a back surface of the second semiconductor device.
7. The manufacturing method of the semiconductor package as claimed in claim 6, wherein when the lid structure is attached to the ring structure, a part of the second semiconductor device is located within the opening pattern.
8. The manufacturing method of the semiconductor package as claimed in claim 1, wherein the first semiconductor device is bonded to an interposer that is bonded to the substrate.
9. The manufacturing method of the semiconductor package as claimed in claim 8, further comprising: bonding a second semiconductor device on the package component in a side by side manner with the first semiconductor device along the edge.
10. The manufacturing method of the semiconductor package as claimed in claim 9, further comprising: providing an encapsulating material over the interposer, such that the encapsulating material encapsulates the first semiconductor device and the second semiconductor device.
11. A manufacturing method of a semiconductor package, comprising: providing a first semiconductor device and a second semiconductor device over a substrate, wherein the first semiconductor device is offset from a center axis of the second semiconductor device that is parallel to an edge of the substrate; attaching a ring structure to the substrate, wherein the ring structure surrounds the first semiconductor device and the second semiconductor device, and comprises an overhang portion cantilevered over the edge of the substrate; and attaching a lid structure to the ring structure, wherein the lid structure covers the first semiconductor device and the second semiconductor device, and comprises an extending portion attaching to the overhang portion.
12. The manufacturing method of the semiconductor package as claimed in claim 11, wherein attaching the ring structure to the substrate comprises providing a first adhesive layer over the substrate.
13. The manufacturing method of the semiconductor package as claimed in claim 12, wherein attaching the lid structure to the ring structure comprises providing a second adhesive layer over the ring structure, and the second adhesive layer completely covers an upper surface of the overhang portion facing the extending portion.
14. The manufacturing method of the semiconductor package as claimed in claim 13, further comprising: performing a curing process for curing the first adhesive layer and the second adhesive layer.
15. The manufacturing method of the semiconductor package as claimed in claim 11 further comprising: providing a surface mounted device over the substrate, wherein the surface mounted device is closer to an opposite edge that is opposite to the edge of the substrate.
16. A manufacturing method of a semiconductor package, comprising: providing a semiconductor device over a substrate; attaching a ring structure to the substrate by a first adhesive layer, wherein the ring structure surrounds the semiconductor device and comprises an overhang portion cantilevered over an edge of the substrate, a major outline of the ring structure is substantially aligned with an outline of the substrate from a top view and the overhang portion protruded from the major outline of the ring structure that is aligned with the edge of the substrate; and attaching a lid structure to the ring structure by a second adhesive layer, wherein the lid structure covers the semiconductor device and comprises an extending portion attaching to the overhang portion through the second adhesive layer.
17. The manufacturing method of the semiconductor package as claimed in claim 16, wherein the semiconductor device comprises a first semiconductor device and a second semiconductor device arranged in a side-by-side manner, wherein the first semiconductor device is offset toward the edge

of the substrate with respect to a center of the second semiconductor device.

18. The manufacturing method of the semiconductor package as claimed in claim 17, wherein the semiconductor device further comprises a surface mounted device disposed at a side of the first semiconductor device, wherein the surface mounted device is closer to an opposite edge that is opposite to the edge of the substrate.

19. The manufacturing method of the semiconductor package as claimed in claim 16, wherein attaching the ring structure to the substrate comprises providing a first adhesive layer over the substrate, and attaching the lid structure to the ring structure comprises providing a second adhesive layer over the ring structure.

20. The manufacturing method of the semiconductor package as claimed in claim 19, wherein the second adhesive layer completely distributed an upper surface of the overhang portion facing the extending portion.

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